Notice of References Cited

Application/Control No. 09/824,965	Applicant(s)/Patent Under Reexamination KAWASE ET AL.		
Examiner	Art Unit	_	
Robert M. Kunemund	1722	Page 1 of 1	

U.S. PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
*	Α	US-4,999,082	03-1991	Kremer et al.	252/62.3GA
*	В	US-5,131,975	07-1992	Bourret-Courchesne, Edith D.	117/82
*	С	US-5,515,810	05-1996	Yamashita, Youji	117/17
	D	US-			
	Е	US-			
	F	US-			
	G	US-			
	Н	US-			
	ı	US-			
	J	US-			
	К	US-			
	L	US-			
	М	US-			

FOREIGN PATENT DOCUMENTS

*		Document Number Country Code-Number-Kind Code	Date MM-YYYY	Country	Name	Classification
*	Ν	0529963	03-1993	Europe		
*	0	60-210599	10-1985	Japan		
*	Р	01037833	02-1989	Japan		
*	Q	64-79087	03-1989	Japan		
*	R	02034597	02-1990	Japan		
*	S	2-74597	03-1990	Japan		
*	Т	3-252399	11-1991	Japan		

NON-PATENT DOCUMENTS

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
*	U	Journal of Japanese Association of Crystal Growth, Y. Okabe et al, Undoped Semi-Insulating GaAs Single Crystals Grtown by the VGF Method vol 18, 1991 pages 88-95
*	V	Kawase, T. " Low disloaction density and low residual strain semi-insulating GaAs grown by vertical boat method"., April 1996
	w	
	x	

*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

Dates in MM-YYYY format are publication dates. Classifications may be US or foreign.